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(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Ritzdorf et al.

Application No.: 09/885,451

Confirmation No.: 3390

Filed: June 20, 2001

Art Unit: 1742

For: METHOD AND APPARATUS FOR LOW  
TEMPERATURE ANNEALING OF  
METALLIZATION MICRO-STRUCTURES  
IN THE PRODUCTION OF A  
MICROELECTRONIC DEVICE

Examiner: W. T. Leader

**AMENDMENT UNDER 37 C.F.R. 1.114**

MS RCE  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**INTRODUCTORY COMMENTS**

In response to the Office Action dated 12 January 2006, please amend the above-identified U.S. patent application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begins on page 2 of this paper.

**Remarks/Arguments** begin on page 9 of this paper.